



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Robert J. Small and Zhefei J. Chen
Title: Compositions for Chemical-Mechanical Planarization of Noble-Metal-Featured Substrates, Associated Methods, and Substrates Produced By Such Methods
Application No.: 10/057,206 Filing Date: January 25, 2002
Examiner: Michael Marcheschi Group Art Unit: 1755
Docket No.: CHEM.003US0 Conf. No.: 1702

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RECEIVED
JUN 23 2004
TC 1700

AMENDMENT

Sir:

This is in response to a final office action that was mailed on December 18, 2003, setting a shortened statutory period for response that expired on March 18, 2004. A three-month extension of time is hereby requested. Entry and consideration of this response are earnestly requested, as it addresses rejections that were newly presented in the final office action. The response is believed to put the application in condition for allowance or in better condition for consideration on appeal. In view of the following amendment and remarks, reconsideration is respectfully requested.

06/22/2004 HVUONG 00000012 10057206
02 FC:1253 950.00 DP